m

	Application No.	Applicant(s)
Notice of Allowability	10/065,015	NGO BUI HUNG ET AL.
	Examiner	Art Unit
	Shih-Chao Chen	2821
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate community GHTS. This application is s	n this application. If not included unication will be mailed in due course. THIS
1. \boxtimes This communication is responsive to <u>the amendment filed</u> of	on Feb. 17, 2004.	
2. The allowed claim(s) is/are <u>1-14</u> .		
3. The drawings filed on are accepted by the Examiner	r.	
 4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION (PTO-152) which give 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OR DECLARATION must be submit 1. A SUBSTITUTE OATH OATH OATH OATH OATH OATH OATH OATH	been received. been received in Application cuments have been received of this communication to file ENT of this application. itted. Note the attached EXA es reason(s) why the oath or t be submitted. on's Patent Drawing Review a Amendment / Comment or 84(c)) should be written on the header according to 37 CF sit of BIOLOGICAL MATE	on No In this national stage application from the din this national stage application from the a reply complying with the requirements AMINER'S AMENDMENT or NOTICE OF declaration is deficient. In the Office action of the drawings in the front (not the back) of FR 1.121(d). ERIAL must be submitted. Note the
Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sı Paper No./ 8), 7. ☐ Examiner's	formal Patent Application (PTO-152) ummary (PTO-413), Mail Date Amendment/Comment Statement of Reasons for Allowance Shib-Chao Chen Examiner Art Unit: 2821

DETAILED ACTION

Drawings

- 1. The drawings were received on Feb. 17, 2004. These drawings are approved by Examiner.
- 2. The application having been allowed, formal drawings are required in response to this office action.

Allowable Subject Matter

- 3. Claims 1-14 are allowed.
- 4. The following is an examiner's statement of reasons for allowance:

The primary reason for the allowance of claims 1-8 and 13-14 is the inclusion of the limitation of for transferring the parameters corresponding to the tuning of the "master" radiating structure to the "slave" radiating structures. It is this limitation found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

The primary reason for the allowance of claims 9-12 is the inclusion of the method steps being transmit the tuning parameters of the master radiating structure to the slave radiating structures; and vary at least one of the tuning parameters. It is these steps found in each of the claims, as they are claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

Art Unit: 2821

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Correspondence

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shih-Chao Chen whose telephone number is (571) 272-1819. The examiner can normally be reached on Monday-Friday from 7 AM to 4:30 PM, First Fri. off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Shih-Chao Chen

Shik-Chao Chen

Examiner Art Unit 2821 Application/Control Number: 10/065,015

Art Unit: 2821

April 12, 2004

Page 4